

# National Institute of Technology Silchar Silchar-788010, India

### Advt. No:

Date:

## Advertisement for Junior Research Fellow (JRF) Position

Applications are invited from motivated and eligible Indian citizens for the position of Junior Research Fellow (JRF) in a sponsored research project of SERB-DST, Govt. of India at the Department of Chemistry, National Institute of Technology Silchar, India with the details mentioned below.

## **Project Details:**

Title of the Project	Nanostructured Metal Oxides Immobilized Ionic Liquids as Green Catalysts for Selective Organic Transformations	
Sponsored Agency	SERB-DST (Govt. of India), New Delhi	
Name of the Post	Junior Research Fellowship (JRF)	
Vacancy	01 Post	
Duration	03 Years	
Principal	Dr. Siddhartha Sankar Dhar, Associate Professor, Department of Chemistry,	
Investigator	National Institute of Technology Silchar, Silchar-788010, India.	
Co-Principal	Dr Avijit Chowdhury, Assistant Professor, Department of Physics, National Institute	
Investigator of Technology Silchar, Silchar-788010, India.		

#### **Other Details:**

	other betans.			
1	Essential Qualifications	M.Sc. in Chemistry/ Applied Chemistry or equivalent degrees with at least 60% marks (or a CGPA of 6.5 in 10 point scale) with valid NET/ GATE /equivalent.		
2	Age Limit and Relaxation	Not more than 28 Years. SC/ST/OBC/Women/PD candidates will get age relaxation as per DST, Govt. of India norms		
3	Fellowship	Rs.25,000.00/- per month for JRF and Rs. 28,000/- per month for SRF, plus HRA as per norms if accommodation is not provided by institute.		
4	Important Instructions	<ul> <li>The assignment is purely temporary in nature and it is co-terminus with the project.</li> <li>All original testimonials would be required to produce for verification purpose at the time of interview.</li> <li>No TA/DA will be paid for appearing in the interview and/or joining of the position.</li> <li>All the terms &amp; conditions for this recruitment will be as per the guidelines of SERB, DST, Govt. of India and NIT Silchar. Institute reserves the right to cancel the recruitment without assigning any reason.</li> <li>Shortlisted candidates will be intimated via E-mail/phone for interview. Candidates are advised to check their Email regularly. Incomplete application will not be accepted.</li> </ul>		
5	How to Apply	Interested candidates must send soft copy of their application as per attached format and self-attested necessary documents, mentioning subject as "Application for JRF under SERB-DST" to the Principal Investigator, Dr. S S Dhar, to ssd_iitg@hotmail.com and/or siddharthashankardhar@gmail.com		
6	Last date for submission of application form	20 August 2018		



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Affix recent

passport size photograph

Project Title: Nanostructured Metal Oxides Immobilized Ionic Liquids as Green Catalysts for Selective Organic Transformations

# Application Form for Junior Research Fellow (JRF) in SERB-DST Sponsored Project

- 1. Name:
- 2. Male/Female:
- 3. Father/Spouse's Name:
- 4. Mother Name:
- 5. Address:(i) Communication address

(ii) Permanent address:

Email id: 7. Phone No:
 Date of birth: 9. Material status:
 Nationality: 11. Caste category (OP/SC/ST/OBC/PH): (Attach documents)
 Mother tongue: 13. Religion:

14. Details of Universities/Institutions attended (from 10<sup>th</sup> Standard onwards) (Attested copies of certificates and mark sheets/grade cards must be attached)

Degree	University/College/	Year	Subject/s	% Marks/	Class
obtained	Board			CGPA/CPI	(if any)

# 15. Professional Qualifying Examination Passed: GATE/NET/Equivalent: (Attested copy of certificate must be attached)

Name of	Subject	Rank /Marks	Qualifying	Valid upto
Examination		/Score/Percentile	date/year	

## 16. Professional Experience (Teaching/Research/Industrial), if any (proof to be attached).

Name of	Position	Type of work	Period	
organization			From	То

17. List of enclosures:

#### 18. Declaration

I hereby declare that the entries made in this application form are correct to the best of my knowledge and belief.

Place:

Signature of the applicant

Date: